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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	•
10/678,573	10/03/2003	Woo Jin Lee	5882P050	2464	٠
8791 7	7590 07/13/2005		EXAM	INER	
BLAKELY SOKOLOFF TAYLOR & ZAFMAN			DOAN, JENNIFER		
12400 WILSH	IRE BOULEVARD				_
SEVENTH FL	OOR		ART UNIT	PAPER NUMBER	
LOCANCELE	CC CA 00025 1020		2074		

DATE MAILED: 07/13/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
Office Action Summan	10/678,573	LEE ET AL.				
Office Action Summary	Examiner	Art Unit				
THE RESERVE THE PARTY AND THE	Jennifer Doan	2874				
The MAILING DATE of this communication ap Period for Reply	opears on the cover sheet with	the correspondence address				
A SHORTENED STATUTORY PERIOD FOR REPITHE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a refl NO period for reply is specified above, the maximum statutory period Failure to reply within the set or extended period for reply will, by statution and the provided period for reply will, by statution and patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a reply ply within the statutory minimum of thirty (3 d will apply and will expire SIX (6) MONTH tte, cause the application to become ABAN	y be timely filed 30) days will be considered timely. S from the mailing date of this communication. IDONED (35 U.S.C. § 133).				
Status						
1)⊠ Responsive to communication(s) filed on <u>03</u>	October 2003.	•				
· _ ·	is action is non-final.					
Disposition of Claims	,					
4)⊠ Claim(s) <u>1-10</u> is/are pending in the applicatio 4a) Of the above claim(s) is/are withdr 5)□ Claim(s) is/are allowed. 6)⊠ Claim(s) <u>1-4,6 and 8</u> is/are rejected. 7)⊠ Claim(s) <u>5,7,9 and 10</u> is/are objected to. 8)□ Claim(s) are subject to restriction and/	awn from consideration.					
Application Papers						
9)⊠ The specification is objected to by the Examir	ner.					
10)⊠ The drawing(s) filed on <u>03 October 2003</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the corre	, , , ,					
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document of: 2. Certified copies of the priority document of: 3. Copies of the certified copies of the priority document of the priority document of the certified copies of the c	nts have been received. nts have been received in Appliority documents have been re au (PCT Rule 17.2(a)).	olication No eceived in this National Stage				
Attachment(s)						
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/06 Paper No(s)/Mail Date 100303 & 091704 	Paper No(s)/N	nmary (PTO-413) Mail Date rmal Patent Application (PTO-152)				

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DETAILED ACTION

Priority

1. Receipt is acknowledged of papers submitted under 35 U.S.C. 119(a)-(d), which papers have been placed of record in the file.

Information Disclosure Statement

2. The prior art documents submitted by applicant in the Information Disclosure Statements filed on 10/03/2003 and 09/17/2004, have all been considered and made of record (note the attached copy of form PTO-1449).

Drawings

3. The drawings, filed on 10/03/2003, are accepted.

Specification

4. Claim 10 is objected to because of the following informalities:

Claim 10, line 7 is missing a period at the end of the claim.

Appropriate correction is required.

Applicants' cooperation is requested in correcting any other errors of which applicants may become aware in the specification.

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Claim Rejections - 35 USC § 102

5. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 6. Claims 1-4, 6 and 8 are rejected under 35 U.S.C. 102(e) as being anticipated by Lee et al. (Korean Article, T74/Photonics Conference translated by translation branch of USPTO).

The applied reference has common inventors with the instant application. Based upon the earlier effective U.S. filing date of the reference, it constitutes prior art under 35 U.S.C. 102(e). This rejection under 35 U.S.C. 102(e) might be overcome either by a showing under 37 CFR 1.132 that any invention disclosed but not claimed in the reference was derived from the inventor of this application and is thus not the invention "by another," or by an appropriate showing under 37 CFR 1.131.

With respect to claim 1, Lee et al. (figure 4) disclose a method for manufacturing an optical waveguide using a laser direct writing method, comprising coating clad

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material on a substrate; coating photo-sensitive polymer on the clad material as a core layer (page 1, the third paragraph, lines 2-4); and forming the optical waveguide using a laser beam having Gaussian distribution (page 1, the third paragraph, lines 4-5), wherein the step of forming the optical waveguide includes the step of overlapping at least two laser beams (page 3, the first paragraph, line 5).

With respect to claim 2, Lee et al. disclose the method, wherein each of the at least two laser beams has difference each other in at least one of the beam's size, the beam's intensity and writing speed (page 2, the first paragraph, lines 1-2).

With respect to claim 3, Lee et al. disclose the method, wherein the refractive index profile of the optical waveguide is asymmetrical (page 3, the first paragraph, lines 1-2).

With respect to claim 4, Lee et al. disclose the method, wherein the optical waveguide is formed with a bending structure (page 1, the first paragraph, lines 10-11).

With respect to claim 6, Lee et al. disclose the method, wherein the number of the laser beam is two, the size and length thereof is few μm (page 1, the second paragraph, lines 3-4).

With respect to claim 8, Lee et al. disclose an optical waveguide formed by a laser direct writing method, comprising a substrate (figure 2); clad material coated on the substrate; and photo-sensitive polymer coated on the clad material as a core layer (page 1, the third paragraph, lines 2-4), wherein the refractive index profile of the core layer has a structure of overlapping at least two laser beams having Gaussian

distribution, spaced a predetermined distance

distribution, spaced a predetermined distance apart each other (page 1, the third paragraph, lines 4-5 and page 3, the first paragraph, line 5).

Allowable Subject Matter

7. Claims 5, 7, 9 and 10 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

The prior art of record fails to disclose or reasonably suggest the method and apparatus, wherein in the overlapped beam of the bending structure, the refractive index of the beam in the outside is larger than that of the beam positioned in the inside as recited in claims 5 and 9; further forming a first bending-shaped optical waveguide using a first laser beam and forming a second bending-shaped optical waveguide having two portions using a second laser beam, wherein the each portion of the second bending-shaped optical waveguides are formed on sides of the first optical waveguides, crossed each other with respect to the center of the bending curve of the first optical waveguide as recited in claims 7 and 10.

Conclusion

8. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Charters et al. (U.S. Patent 6,577,799) disclose a laser direct writing of planar light wave circuits. And Livesay et al. (U.S. 2003/0038251) disclose a

method and apparatus for forming optical material in which the electron beam (not laser beam) is overlapping.

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9. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jennifer Doan whose telephone number is (571) 272-2346. The examiner can normally be reached on Monday to Thursday from 6:00 am to 3:30 pm, second Friday off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Rodney Bovernick can be reached on (571) 272-2344. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Jennifer Doan

Patent examiner

July 7, 2005